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Rapid Communication

Removal of submicron particles from solid surfaces using surfactants

F.M. Mahdi a, T.E. Record a, C.A. Amadi a, F.O. Emmanuel a, N. Ivanova b, A. Trybala a, V.M. Starov a,*

a Department of Chemical Engineering, Loughborough University, Loughborough, Leicestershire LE11 3TU, UK
b Institute of Physics and Technology, Tyumen State University, Semakova 10, Tyumen 625003, Russia

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The currently increasing focus on nanotechnology and the use of microstructures is beneficial to a number of industries, as well as to the ever improving quality of consumer products. However, nanoparticles have a tendency to bind to solid surfaces with incredible strength and can cause fouling to micro-structured devices [1]. This resilience is due to various intermolecular forces between the particles and the surface, such as Van der Waals, electrostatic forces and hydrogen bonding [2]. The effect of nanoparticle fouling on microstructures, however, is relatively unknown despite rising industrial interest in their uses [3].

There are a number of current methods to remove nanoparticles from solid surfaces such as those using nanobubbles [4], megasonics [5], lasers [6], aerosols [5] and chemical etching [7] among others. Although the previously mentioned techniques have shown to be effective at nanoparticle sizes as low as 10 nm, many have notable drawbacks. Examples of this include the required use of highly specialised equipment, which demand precise optimisation to be used effectively and sensitivity to fluctuations in parameters such as temperature [5]. Many of the methods, particularly those using lasers, operate on a very small area, making the cleaning of larger surfaces significantly more difficult.

The use of suitable selection of surfactants to remove two different types of nanoparticles from solid surfaces is proposed below in order to develop an easier and reliable procedure, which has the potential to be carried out without astronauts interference inside a spacecraft.

Below we investigate all possible scenarios with regard to the nature of the surface and particles and surfactants. The surfactants used were selected due to their range of properties, such as critical micelle concentration (CMC) and hydrophile–lipophile balance (HLB), and were used for all combinations of hydrophilic (HL) and hydrophobic (HB) nanoparticles and surfaces in order to investigate the most effective for each of four possible scenarios.

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bath for an hour to have a homogeneous suspension. The first half of the experiments (HB particles on HB substrate and HB particles on HL substrate) were conducted using the carbon suspensions and the latter half (HL particles on HL substrates and HL particles on HB substrates) using silica suspensions. The HL and HB surfaces where the particles were deposited onto were glass slides (HL) and Teflon film (HB), respectively. These materials were chosen due to the variety of industrial applications in which they are used, such as windows and containers for glass and a range of aerospace components made of Teflon. After the slides had been cleaned, as discussed above, a 5 μL droplet of a suspension was deposited onto the centre of each solid substrate using a micropipette. The slides were then covered in order to protect the droplets from contamination and left for 24 h to dry.

Table 1 shows the chosen surfactants and their properties including critical micelle concentration (CMC), hydrophilic–lipophilic balance (HLB), pH and conductivity values (at 1 CMC). This selection of surfactants provided a suitable variety of CMCs and other properties required.

<table>
<thead>
<tr>
<th>Type</th>
<th>Surfactant</th>
<th>CMC mM</th>
<th>HLB</th>
<th>pH</th>
<th>Cond. μs/cm</th>
</tr>
</thead>
<tbody>
<tr>
<td>Anionic</td>
<td>Sodium dodecyl sulphate (SDS)</td>
<td>8.2a</td>
<td>40.0</td>
<td>7</td>
<td>702</td>
</tr>
<tr>
<td></td>
<td>Sodium 1-octanesulfonate monohydrate (1-SOS)</td>
<td>155b</td>
<td>41.9</td>
<td>5.5</td>
<td>8529</td>
</tr>
<tr>
<td></td>
<td>Sodium 1-dodecanesulfonate (1-SDS)</td>
<td>7c</td>
<td>9.7</td>
<td>6.3</td>
<td>446</td>
</tr>
<tr>
<td></td>
<td>Triton X-100 (T-X-100)</td>
<td>0.24d</td>
<td>13.5</td>
<td>6.2</td>
<td>180</td>
</tr>
<tr>
<td></td>
<td>Tween 20 (T-20)</td>
<td>0.05e</td>
<td>16.7</td>
<td>5.9</td>
<td>370</td>
</tr>
<tr>
<td>Non-ionic</td>
<td>Novex™ FC-4430</td>
<td>0.17f</td>
<td>–</td>
<td>6</td>
<td>18</td>
</tr>
<tr>
<td></td>
<td>Novex™ FC-4432</td>
<td>0.5g</td>
<td>–</td>
<td>4.6</td>
<td>28</td>
</tr>
<tr>
<td></td>
<td>Dodecytrimethylammonium bromide (DoTAB)</td>
<td>11h</td>
<td>12</td>
<td>6.7</td>
<td>1070</td>
</tr>
<tr>
<td></td>
<td>Myristytrimethylammonium bromide (MTAB)</td>
<td>4i</td>
<td>14</td>
<td>5.7</td>
<td>387</td>
</tr>
</tbody>
</table>

A: From experimental data; B: [8]; C: [9]; D: Sigma-Aldrich, 2015; E: [10]; F: [11]; G: [11].

a All HLB values were calculated using the Davies method [12].

Fig. 1. a–Schematic presentation of the methodology steps; b–diagram of the experimental apparatus.
Droplets of 5 μL of each suspension with a range of concentrations for each type were deposited onto glass slides with and without Teflon film attached to the slide. The Teflon film was attached to a slide using a double sided tape. The droplets were then left for 24 h to evaporate, allowing for the particle to be completely deposited onto the substrate used. It has been decided that the residual particle deposits on the corresponding solid support should be visible under a microscope. The following concentrations were selected according to this requirement: 0.2% and 6% w/w for carbon and silica suspensions, respectively.

After that a bigger droplet (7.5 μL) of surfactant solutions (secondary droplet) was deposited on the solid substrate to cover completely the residual particles on the solid substrate. Solutions for each type of surfactant were produced over a range of concentrations relative to the corresponding CMC. The concentrations chosen were 0.5, 1, 5, 10 and 15 CMC for each type of surfactant.

It was necessary to select an exposure time after a deposition of the secondary droplet to make sure that the removal of residual particles is completed. It was found that 0.5 CMC droplets of SDS has the weakest removal effect. That is droplets of 7.5 μL of SDS with a concentration of 0.5 CMC were applied to each sample and left for 1, 2, 4, 10 and 15 min. A concentration of 0.5 CMC (being the weakest concentration) was used for these experiments as it should require the longest time to finalise the process. This meant that the selected time period would be suitable even for the worst case scenario in terms of time. The duration of secondary droplet deposition was selected as 4 min.

The secondary droplets were then removed from the sample using the same syringe with a precision vacuum operated at 5 kPa. It was discovered previously that even as vacuum pressures as 100 kPa was unable to remove the residual particles by itself. A pressure of 5 kPa was therefore selected as it posed no threat of damage of the samples and provided adequate suction for the removal of the secondary droplet of surfactant.

In order to investigate the effect of the surfactant on the particles removal the slide with the dry nanoparticle placed underneath a high speed camera as shown in Fig. 1b. AVT Smart View software within a PC was used to take and analyse the droplet images. Camera settings were identical throughout.

A 7.5 μL droplet of surfactant was deposited to fully cover the residual particles on the slide and left for 4 min to draw the particles into solution. The droplet was then removed from the surface using the precision vacuum and an image was taken. The schematic presentation of the methodology steps is shown in Fig. 1a. Deposition of the secondary droplet and its removal was repeated until either the slide was entirely clean (based on the naked eye observation) or until the particles remained completely unchanged after five applications of secondary droplets. For some samples which showed no change from the start, 15 applications were used in order to allow the surfactant sufficient opportunity to remove the particles.

The described above procedure was repeated for all surfactants and for all combinations of HB and HL surfaces and particles.

To investigate the cleaning efficiency of the surfactant, the slide with a residue after complete evaporation of the initial droplet was placed underneath a high speed camera (640 × 480, 1:1.4) as shown in Fig. 1b. The percentage of removal (cleaning) was calculated for each sample by analysing the initial area of the droplet and the final residue area covered by particles using ImageJ software. The final residue area is the summation of all particles, spots and cluster areas that are present in the final image. In the case of samples which were seemed clean using these camera resolution, a high resolution microscope (0.90 μm/pix) was used for further check and analysis any particles, spots and cluster areas. Once all images had been collected, the percentage of removal (cleaning) was calculated for each sample by analysing the initial and final residues area with ImageJ software using Eq. (1). The cleaning efficiency ($E$) is found by subtracting the summation of the final particles area ($A_{fi}$), the final cluster area ($A_{fc}$) and the final spots area ($A_{fs}$) from the initial droplet area ($A_{ni}$). The output is divided by the initial droplet area in order to find the cleaning efficiency as a ratio of the initial droplet area.

$$
E = \frac{A_{ni} - \sum (A_{fp}, A_{fc}, \ldots A_{fs})}{A_{ni}} \times 100.
$$

In the case of Hydrophobic Nanoparticles on a Hydrophilic Surface (HB on HL) MTAB (cationic), FC-4432 (non-ionic), 1-SDDS (anionic) and T-20 (non-ionic) are by far the most effective cleaning surfactants, with samples consistently being above 90% cleaned: the surfactants cleaning efficiency reaches peak values of 98.9, 98.0, 98.4 and 95.7% for concentration of 5, 0.5, 10 and 5 CMC, respectively.

However, in the case of HB on HL, water alone turns out the best cleaning agent: close to 100% cleaning efficiency.

For Hydrophilic Nanoparticles on a Hydrophilic Surface (HL on HL) the surfactants generally followed clear relationships with increasing concentration. From Fig. 2(a, b) the non-ionic surfactants (a) show very poor cleaning efficiency, in general, less than 35% compared to anionic (60%) and cationic surfactants (98%).

DoTAB shows the best performance in this case attaining a max removal of 98.13% and levelling off at around 5 CMC. MTAB also displayed a significant removal, though it only achieved its peak removal of 82.93% at 10 CMC before declining. None of the other surfactants attained removal values higher than 65%, as seen in Fig. 2(a, b). Furthermore, from the same figure, it can be seen that water alone is extremely poor at removing HL nanoparticles, with a removal efficiency of 1.4%.

Hydrophobic Nanoparticles on a Hydrophilic Surface (HB on HB) scenario all types of surfactants used in this research performed significantly worse than in all other scenarios, with the highest percentage of cleaning being 1-SDDS at a peak of 53%. Similarly to HB on HL scenario, an anionic surfactant showed a better effective cleaning. Using only

![Fig. 2. Variation of the percentage of nanoparticle removal with respect to surfactant concentration.](image-url)
shown that for certain scenarios, surfactants can be used to achieve nanoparticle removal is viable for a range of scenarios. It has also been surfactant used and will require further investigation. that cationic DoTAB surfactants were optimal as cleaning agents. terms of cleaning ef
tions is proposed. The surfactants’ cleaning ef
ments, it became apparent that the way that the carbon nanoparticles
arranged themselves onto the surface was very different.

A method of nanoparticle removal using aqueous surfactant solutions is proposed. The surfactants’ cleaning efficiency is investigated for all four combinations of hydrophilic (HL) and hydrophobic (HB) nanoparticles and surfaces, in order to find the most successful cleaning method in each combination. Carbon and silica nanoparticles deposited onto Teflon and glass surfaces were used. Cationic, anionic and non-ionic surfactants with a range of CMCs were used in order to identify the best surfactant in each scenario. It was found that for the HB on HL and HL on HB scenarios, water is more effective than all surfactants in terms of cleaning efficiency. For the HL on HL scenario, it was discovered that cationic DoTAB surfactants were optimal as cleaning agents. However, the HB on HB scenario proved resilient to water and each surfactant used and will require further investigation.

This work has clearly demonstrated that the use of surfactants for nanoparticle removal is viable for a range of scenarios. It has also been shown that for certain scenarios, surfactants can be used to achieve significantly high cleaning rates than using water alone, solidifying the technique as a simple, effective and cost efficient method.

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## References


### Table 2

The average initial particle deposition area and standard deviation for each scenario.

<table>
<thead>
<tr>
<th>Scenario</th>
<th>Average initial area, mm²</th>
<th>Standard deviation</th>
</tr>
</thead>
<tbody>
<tr>
<td>HB on HL</td>
<td>38.60</td>
<td>3.62</td>
</tr>
<tr>
<td>HL on HL</td>
<td>26.01</td>
<td>1.42</td>
</tr>
<tr>
<td>HB on HB</td>
<td>4.23</td>
<td>0.60</td>
</tr>
<tr>
<td>HL on HB</td>
<td>2.28</td>
<td>0.36</td>
</tr>
</tbody>
</table>

Acknowledgements

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